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**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

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| Application Number | 09/592,839 |
| Filing Date | 6/13/2000 |
| First Named Inventor | Nadabar et al. |
| Group Art Unit | 2623 |
| Examiner Name | Dastouri, Mehrdad |
| Attorney Docket Number | C00-013 |

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| Examiner Initials* | Cite No. ¹ | U.S. Patent Document | | Name of Patentee or Applicant of Cited Document | Date of Publication of Cited Document MM-DD-YYYY | Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear |
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Examiner
Signature*Mehrdad Dastouri*Date
Considered*1/22/04*

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| Examiner Name | |
| Attorney Docket Number | COO-013 Technology Center 2600 |

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| Examiner Initials* | Citation No. | Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published. | T ² |
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| Examiner Signature | Mehrdad Dastgiri | Date Considered | 1/22/04 |
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